



MAY 26 2004

TRANSMITTAL OF FORMAL DRAWINGS

Docket No.

SLA0749

In Re: Application Of: Jer-Shen Maa, Jong-Jan Lee, Douglas J. Tweet and Sheng Teng Hsu

Serial No.	Filing Date	Batch No.	Examiner	Art Unit
10/625,015	07/22/2003		Tuan H. Nguyen	2813

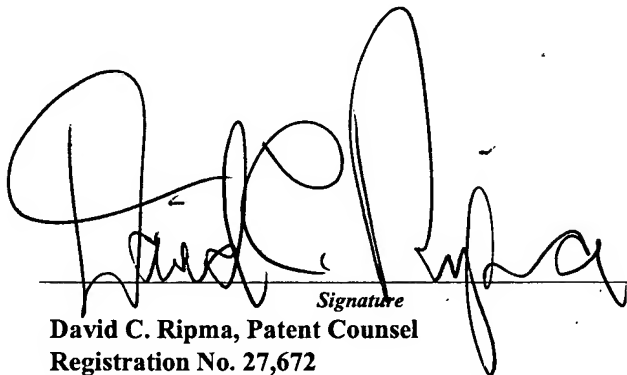
Invention: Method of Forming Relaxed SiGe Layer

Address to:

Assistant Commissioner for Patents
Washington, D.C. 20231

Transmitted herewith are:

3 sheets of formal drawing(s) for this application.

Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c)
on the reverse side of the drawing.
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Dated: May 24, 2004

I certify that this document and attached formal drawings
are being deposited on May 24, 2004 with the
U.S. Postal Service as first class mail under 37 C.F.R. 1.8
and addressed to the Assistant Commissioner for Patents,
Washington, D.C. 20231.
Signature of Person Mailing Correspondence

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